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	Application No.	Applicant(s)	
Nation of Allowability	10/015,446	KANETSUKI ET AL.	
Notice of Allowability	Examiner	Art Unit	
	Lan Vinh	1765	
The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication IGHTS. This application is subject to	olication. If not include will be mailed in due	ed course. <b>THIS</b>
1. $\boxtimes$ This communication is responsive to <u>The amendment and</u>	response filed on 11/18/2004.		
2.  The allowed claim(s) is/are <u>1,5-9 and 15-19</u> .			
3. $\boxtimes$ The drawings filed on <u>12 December 2001</u> are accepted by	the Examiner.		
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority un</li> <li>a)  All b)  Some* c)  None of the:</li> <li>1.  Certified copies of the priority documents have</li> </ul>			
		0/015 446	
3. Copies of the certified copies of the priority doc			tion from the
International Bureau (PCT Rule 17.2(a)).		Tational otago applicat	
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a reply of this communication.	complying with the rec	uirements
<ol> <li>A SUBSTITUTE OATH OR DECLARATION must be submi INFORMAL PATENT APPLICATION (PTO-152) which give</li> </ol>	itted. Note the attached EXAMINER' es reason(s) why the oath or declarate	S AMENDMENT or N tion is deficient.	OTICE OF
<ol> <li>CORRECTED DRAWINGS (as "replacement sheets") mus</li> <li>(a) including changes required by the Notice of Draftspers</li> <li>1) hereto or 2) to Paper No./Mail Date</li> <li>(b) including changes required by the attached Examiner's Paper No./Mail Date</li> </ol>	on's Patent Drawing Review ( PTO-	·	·
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the	84(c)) should be written on the drawing he header according to 37 CFR 1.121(c	gs in the front (not the	back) of
<ol> <li>DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT I</li> </ol>	sit of BIOLOGICAL MATERIAL m FOR THE DEPOSIT OF BIOLOGICA	nust be submitted. N AL MATERIAL.	lote the
Attachment(s)			
1. Notice of References Cited (PTO-892)	5. Notice of Informal Page	atent Application (PTC	)-152) <sup>-</sup>
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary	(PTO-413),	·
<ol> <li>Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date 32604, 82404</li> </ol>	Paper No./Mail Date 8), 7. ☐ Examiner's Amendm		
4. ☐ Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's Stateme	nt of Reasons for Allo	wance
of Biological Material	9.  Other		
		Lan Vinh AU 1765	

U.S. Patent and Trademark Office PTOL-37 (Rev. 1-04) 010505 Application/Control Number: 10/015,446

Art Unit: 1765

## Allowable Subject Matter

1. Claims 1,5-9, 15-19 allowed.

The following is an examiner's statement of reasons for allowance:

Regarding claims 1, 7, 15, the applicants have presented a persuasive argument, see pages 10-11 of the response, filed on 11/18/2004, that the cited prior art of record fails to disclose or render obvious a plasma processing method wherein when said substrate is etched by the plasma in a plasma generation period, and a change is made in plasma generating condition according to any of said film that are to be etched, said plasma generating condition for stably maintaining generating of the plasma is first changed and thereafter a change is made in said process gas, in combination with the rest of the limitations of claims 1, 7, 15. The closest cited prior art of Hsia et al (US 6,328,848) discloses a plasma processing method wherein when a substrate is etched by the plasma in a plasma generation period, plasma generating condition for stably maintaining generating of the plasma (power, pressure) and process gas are both changed during in same period (col 10, lines 30-40)

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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## Conclusion

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2. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lan Vinh whose telephone number is 571 272 1471. The examiner can normally be reached on M-F 8:30-5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571 272 1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

January 5, 2005